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**INFORMATION DISCLOSURE  
STATEMENT BY APPLICANT**

(use as many sheets as necessary)

Sheet 1

of

Application Number 09/743,704

Filing Date January 16, 2001

First Named Inventor Isao HORIUCHI

Group Art Unit 1614

Examiner Name D. Jagoe

Attorney Docket Number HORIUCHI=4

**U.S. PATENT DOCUMENTS**

Examiner Initials*	Cite No. <sup>1</sup>	U.S. Patent Document		Name of Patentee or Applicant of Cited Document	Date of Publication of Cited Document MM-DD-YYYY	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		Number	Kind Code <sup>2</sup> (if known)			
<i>[Signature]</i>	AA	5,324,515	A	Ho LEE et al	06-28-0994	

**FOREIGN PATENT DOCUMENTS**

Examiner Initials*	Cite No. <sup>1</sup>	Foreign Patent Number			Name of Patentee or Applicant of Cited Document	Date of Publication of Cited Document MM-DD-YYYY	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	T <sup>6</sup>
		Office <sup>3</sup>	Number	Kind Code <sup>5</sup> (if known)				
<i>[Signature]</i>	AB	GB	1 237 656		Joannis Demetris MINA	06-30-1971		

**OTHER PRIOR ART - NON PATENT LITERATURE DOCUMENTS**

Examiner Initials*	Cite No. <sup>1</sup>	Include name of the author (in CAPITAL LETTERS), title of article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published	T <sup>2</sup>
<i>[Signature]</i>	AC	Patent Abstracts of Japan, JP 60 197613, Applicant ASAI TAKI, entitled "Hair Tonic Solution from Natural Products", published October 7, 1985.	
<i>[Signature]</i>	AD	Patent Abstracts of Japan, JP 11-124383, Applicant TANAKA HIDEZO, entitled "Production of Light-Resistant Copper Chlorophylline Alkaline Salt and its Uses", published May 11, 1999.	

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<sup>1</sup> Unique citation designation number. <sup>2</sup> See attached Kinds of U.S. Patent Documents. <sup>3</sup> Enter Office that issued the document, by the two-letter code (WIPO Standard ST.3). <sup>4</sup> For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. <sup>5</sup> Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST.16 if possible. <sup>6</sup> Applicant is to place a check mark here if English language Translation is attached.